

Freeform Search

Database:	US Pre-Grant Publication Full-Text Database US Patents Full-Text Database US OCR Full-Text Database EPO Abstracts Database JPO Abstracts Database Derwent World Patents Index IBM Technical Disclosure Bulletins
Term:	(deposition adj chamber) and (offset adj data adj structure) and (computer adj memor\$3) and (resolve adj differences adj between adj
Display:	<input type="text" value="50"/> Documents in Display Format: <input type="text" value="-"/> Starting with Number <input type="text" value="1"/>
Generate: <input type="radio"/> Hit List <input checked="" type="radio"/> Hit Count <input type="radio"/> Side by Side <input type="radio"/> Image	

Search History

DATE: Tuesday, January 25, 2005 [Printable Copy](#) [Create Case](#)

<u>Set</u> <u>Name</u>	<u>Query</u>	<u>Hit</u> <u>Count</u>	<u>Set</u> <u>Name</u> result set
side by side			
	DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=NO; OP=OR		
<u>L19</u>	(deposition adj chamber) and (offset adj data adj structure) and (computer adj memor\$3) and (resolve adj differences adj between adj measurements)	2	<u>L19</u>
<u>L18</u>	(deposition adj chamber) and (offset adj data adj structure) and (computer adj memor\$3) and (first adj parameter) and (second adj parameter)	2	<u>L18</u>
<u>L17</u>	5871805.pn.	2	<u>L17</u>
<u>L16</u>	(deposit\$3 adj chamber) and (configur\$3) and (wafers) and (measur\$3 adj3 thickness adj3 wafer) and (pattern)	8	<u>L16</u>
<u>L15</u>	(deposit\$3 adj chamber) and (configur\$3 adj3 parameter) and (wafers)	29	<u>L15</u>
<u>L14</u>	(deposit\$3 adj chamber) and (configur\$3 adj3 parameter) and (wafers) and (pattern adj5 thickness)	0	<u>L14</u>
<u>L13</u>	(deposit\$3 adj chamber) and (configur\$3 adj3 parameter) and (wafers) and (wafer adj3 thickness)	0	<u>L13</u>
<u>L12</u>	(deposit\$3 adj chamber) and (configur\$3 adj3 parameter) and (wafers) and (wafer adj3 thickness) and (pattern)	0	<u>L12</u>
<u>L11</u>	(deposit\$3 adj chamber) and (configur\$3 adj3 parameter) and (wafers) and (wafer adj3 tickness) and (pattern)	0	<u>L11</u>
<u>L10</u>	(deposit\$3 adj chamber) and (configur\$3 adj3 parameter) and (wafers) and (measur\$3 adj tickness) and (pattern)	0	<u>L10</u>
	(deposit\$3 adj chamber) and (configur\$3 adj3 parameter) and (wafers) and		

<u>L9</u>	(measur\$3 adj tickness) and (deposition adj pattern)	0	<u>L9</u>
<u>L8</u>	(deposit\$3 adj chamber) and (configur\$3 adj3 parameter) and (wafers) and (measur\$3 adj thickness) and (pattern)	28	<u>L8</u>
<u>L7</u>	(deposit\$3 adj chamber) and (configur\$3 adj3 parameter) and (wafers) and (thickness) and (pattern)	29	<u>L7</u>
<u>L6</u>	(deposit\$3 adj chamber) and (configur\$3 adj3 parameter) and (wafers) and (thickness) and (pattern)	29	<u>L6</u>
<u>L5</u>	(deposit\$3 adj chamber) and (configur\$3 adj parameter) and (wafers) and (thickness) and (pattern)	0	<u>L5</u>
<u>L4</u>	(deposit\$3 adj chamber) and (configur\$3 adj parameter) and (wafers) and (measur\$3 adj thickness) and (pattern)	0	<u>L4</u>
<u>L3</u>	(deposit\$3 adj chamber) and (configur\$3 adj parameter) and (wafers) and (measur\$3 adj thickness) and (deposition adj pattern)	0	<u>L3</u>
<u>L2</u>	(deposit\$3 adj chamber) and (configur\$3 adj parameter) and (wafers) and (measur\$3 adj tickness)	0	<u>L2</u>
<u>L1</u>	(deposit\$3 adj chamber) and (configur\$3 adj parameter) and (wafers) and (measur\$3 adj tickness) and (deposition adj pattern)	0	<u>L1</u>

END OF SEARCH HISTORY